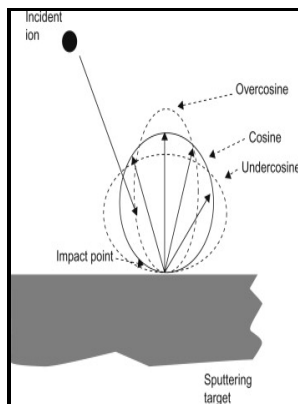


Dose effects in gas ion sputtering of gold.

University of Salford - Sputtering studies of monocrystalline gold



Description: -
-Dose effects in gas ion sputtering of gold.
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D3809/73Dose effects in gas ion sputtering of gold.
Notes: PhD thesis, Electrical Engineering
This edition was published in 1973



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Tags: #What #Is #Sputtering? #Magnetron #Sputtering?

Sputter deposition

The high hardnesses of the films on SS 304 were attributed to the high residual stress in the film, which is due to the large thermal expansion coefficient between the film and the SS substrate. The microscratch curve tests showed critical loads of 60 N, which showed that the coatings had excellent adhesion. IBS has found application in the manufacture of thin-film heads for.

Collision

TOXICOLOGICAL INFORMATION Information on toxicological effects Acute toxicity: The Registry of Toxic Effects of Chemical Substances RTECS contains acute toxicity data for this substance. In addition, the deposition time and distance, ion kinetic energy and coating method also affect the quality of coatings. It can also cause premature pump failure.

Gold Germanium Sputtering Target

Physical vapor deposition of radiopaque markings on a graft 2000-06-22 2003-11-25 Advanced Cardiovascular Systems, Inc.

The effect of deposition conditions on the properties of Zr

This symmetrical behavior comes from the fcc {001} planes with an atomic arrangement of four-fold rotational symmetry and a mirror-image symmetry between each of the two high-symmetry rotational axes. This is not only visible in the small energy loss that ions experience in these directions but also from the width of the channels as can easily be seen by comparing figures b with b.

Sputtering studies of monocrystalline gold

It describes the role of various process parameters used during the deposition of advanced functional coatings. Because the cap is frequently removed, every time fuel is added to the vehicle, it can and will need to be replaced.

BJNANO

The amount of ablated material during pulse generation plays an important role in achieving a high crystalline quality film. The films with the 111 preferred orientation are expected to show higher hardness.

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